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PATENT APPLICATION

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

SHINICHI KAWATE ET AL.

Application No.: 09/940,642

Filed: August 29, 2001

For: ELECTRON-EMITTING DEVICES
ELECTRON SOURCES, AND IMAGE
FORMING APPARATUS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SUBMISSION OF PARTIAL ENGLISH TRANSLATION OF FOREIGN COMMUNICATION

Sir:

Supplement to the Information Disclosure Statement filed in the Patent and
Trademark Office on November 30, 2005, this Submission is being filed.

A copy of a Japanese Official Letter issued in a foreign counterpart application was submitted with the Supplemental Information Disclosure Statement. A further copy of the Japanese Official Letter is provided herewith as a supplement thereto, for the Examiner's convenience. Applicants now respectfully submit the attached paper entitled "Reason for Refusal" (pages 2-7), prepared by the Applicants, which includes at least a partial English

I hereby certify that this correspondence is being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on
March 9, 2005

(Date of Deposit)

Frank A. DeLucia (42,476)
(Name of Attorney for Applicants)

Signature
(Name)

March 9, 2005
Date of Signature

Translation of the Japanese Official Letter. Also, the attached "Reason for Refusal" includes therein (by insertion) for the Examiners convenience, English translations of relevant portions of prior art references cited in the Japanese Official Letter (and referred to in the Supplemental Information Disclosure Statement). The Examiner is respectfully referred to the attached paper ("Reason for Refusal") for a further explanation of relevance of the references mentioned therein. All of those references were cited in previous Information Disclosure Statements in the present application.

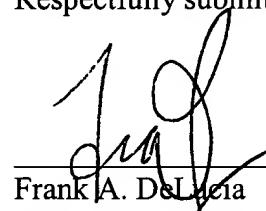
Furthermore, for a further explanation of relevance of previously cited Japanese document 2000-277003, the Examiner is respectfully referred to U.S. Patent Application Publication No. 2002/0136896 A1, published September 26, 2002. No copy of the U.S. Patent Application Publication is provided herewith because it is a U.S. published patent application available from the Patent and Trademark Office. Also, the publication is not identified on a Form PTO-1449 form because it is referred to merely to provide a concise statement of relevance of previously cited Japanese document 2000-277003.

Copies of the documents cited in the Japanese Office Action are not submitted herewith, since the documents have been previously submitted and cited in at least one of Information Disclosure Statements filed on November 30, 2004 and September 9, 2003. Since the Japanese references were previously cited in Disclosure Statements timely filed in the present application, it is believed that no fee is due in connection with the present Submission. However, should a fee be deemed necessary, authorization is hereby granted to charge Deposit Account 06-1205 for the necessary fee.

Entry and consideration hereof are earnestly solicited, and the Examiner is respectfully requested to confirm in writing that he has considered the present Submission and attachment.

Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,



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